

L Number	Hits	Search Text	DB	Time stamp
1	3759	438/595.ccls. 438/638.ccls. 438/639.ccls. 438/640.ccls. 438/672.ccls. 438/675.ccls. 257/775.ccls.	USPAT; US-PGPUB	2004/10/18 09:51
2	3	6740916.pn. 6617631.pn. 6083788.pn.	USPAT; US-PGPUB	2004/10/18 09:54
3	58	(438/595.ccls. 438/638.ccls. 438/639.ccls. 438/640.ccls. 438/672.ccls. 438/675.ccls. 257/775.ccls.) and ((gate wordline bitline ((word bit metal conduct\$6) adj (line trace runner interconnect\$6))) same (hole opening via trench groove window) same (contact plug stud land\$6 pad) same (taper\$6 funnel conical cone))	USPAT; US-PGPUB	2004/10/18 10:25
4	559	((gate wordline bitline ((word bit metal conduct\$6) adj (line trace runner interconnect\$6))) same (hole opening via trench groove window) same (contact plug stud land\$6 pad) same (taper\$6 funnel conical cone)) and (semiconductor wafer silicon substrate)	USPAT; US-PGPUB	2004/10/18 10:29
9	361	((hole opening via trench groove window) with (liner spacer sidewall (side adj wall))) and (contact plug stud land\$6 pad) and (taper\$6 funnel conical cone (isotropic\$8 with etch\$6)) and (semiconductor wafer silicon substrate)	EPO; JPO; DERWENT; IBM_TDB	2004/10/18 10:22
12	784	((hole opening via trench groove window) with (liner spacer sidewall (side adj wall))) same (contact plug stud land\$6 pad) same (taper\$6 funnel conical cone)) and (semiconductor wafer silicon substrate)	USPAT; US-PGPUB	2004/10/18 10:28
10	118	(438/595.ccls. 438/638.ccls. 438/639.ccls. 438/640.ccls. 438/672.ccls. 438/675.ccls. 257/775.ccls.) and ((gate wordline bitline ((word bit metal conduct\$6) adj (line trace runner interconnect\$6))) same (hole opening via trench groove window) same (contact plug stud land\$6 pad) same (taper\$6 funnel conical cone (isotropic\$8 with etch\$6)))	USPAT; US-PGPUB	2004/10/18 10:30
11	87	(438/595.ccls. 438/638.ccls. 438/639.ccls. 438/640.ccls. 438/672.ccls. 438/675.ccls. 257/775.ccls.) and (((hole opening via trench groove window) with (liner spacer sidewall (side adj wall))) same (contact plug stud land\$6 pad) same (taper\$6 funnel conical cone))	USPAT; US-PGPUB	2004/10/18 11:06
13	111	((gate wordline bitline ((word bit metal conduct\$6) adj (line trace runner interconnect\$6))) same ((hole opening via trench groove window) with (liner spacer sidewall (side adj wall))) same (contact plug stud land\$6 pad) same (taper\$6 funnel conical cone)) and (semiconductor wafer silicon substrate)	USPAT; US-PGPUB	2004/10/18 11:40
7	204	(gate wordline bitline ((word bit metal conduct\$6) adj (line trace runner interconnect\$6))) and (hole opening via trench groove window) and (contact plug stud land\$6 pad) and (taper\$6 funnel conical cone) and (semiconductor wafer silicon substrate)	EPO; JPO; DERWENT; IBM_TDB	2004/10/18 12:07
8	209	((hole opening via trench groove window) with (liner spacer sidewall (side adj wall))) and (contact plug stud land\$6 pad) and (taper\$6 funnel conical cone) and (semiconductor wafer silicon substrate)	EPO; JPO; DERWENT; IBM_TDB	2004/10/18 12:50
5	317	((gate wordline bitline ((word bit metal conduct\$6) adj (line trace runner interconnect\$6))) same ((hole opening via trench groove window) with (taper\$6 funnel conical cone)) same (contact plug stud land\$6 pad)) and (semiconductor wafer silicon substrate)	USPAT; US-PGPUB	2004/10/18 14:12